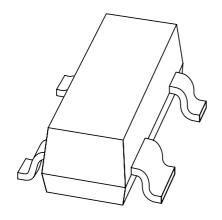
DISCRETE SEMICONDUCTORS

DATA SHEET



BF992 Silicon N-channel dual gate MOS-FET

Product specification Supersedes data of 1996 Jul 30 1999 Aug 11





Silicon N-channel dual gate MOS-FET

BF992

APPLICATIONS

 VHF applications such as VHF television tuners and FM tuners with 12 V supply voltage. The device is also suitable for use in professional communications equipment.

DESCRIPTION

Depletion type field-effect transistor in a plastic micro-miniature SOT143B package with source and substrate interconnected.

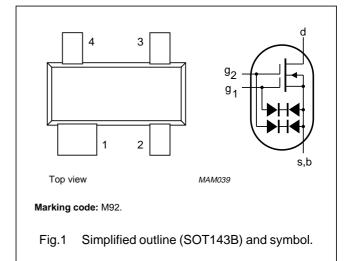
The transistor is protected against excessive input voltage surges by integrated back-to-back diodes between gates and source.

CAUTION

The device is supplied in an antistatic package. The gate-source input must be protected against static discharge during transport or handling.

PINNING

PIN	SYMBOL	DESCRIPTION
1	s, b	source
2	d	drain
3	g ₂	gate 2
4	9 1	gate 1



QUICK REFERENCE DATA

SYMBOL	PARAMETER	CONDITIONS	TYP.	MAX.	UNIT
V _{DS}	drain-source voltage (DC)		_	20	V
I _D	drain current (DC)		_	40	mA
P _{tot}	total power dissipation	T _{amb} = 60 °C	_	200	mW
Y _{fs}	forward transfer admittance	$f = 1 \text{ kHz}; I_D = 15 \text{ mA}; V_{DS} = 10 \text{ V}; V_{G2-S} = 4 \text{ V}$	25	_	mS
C _{ig1-s}	input capacitance at gate 1	$f = 1 \text{ MHz}; I_D = 15 \text{ mA}; V_{DS} = 10 \text{ V}; V_{G2-S} = 4 \text{ V}$	4	_	pF
C _{rs}	reverse transfer capacitance	$f = 1 \text{ MHz}; I_D = 15 \text{ mA}; V_{DS} = 10 \text{ V}; V_{G2-S} = 4 \text{ V}$	30	_	fF
F	noise figure	$G_S = 2 \text{ mS}; I_D = 15 \text{ mA}; V_{DS} = 10 \text{ V}; V_{G2-S} = 4 \text{ V}; f = 200 \text{ MHz}$	1.2	_	dB
Tj	operating junction temperature		_	150	°C

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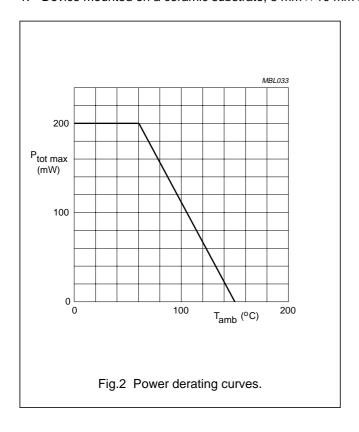
LIMITING VALUES

In accordance with the Absolute Maximum Rating System (IEC 134).

SYMBOL	PARAMETER	CONDITIONS	MIN.	MAX.	UNIT
V _{DS}	drain-source voltage		_	20	V
I _D	drain current		_	40	mA
I _{G1}	gate 1 current		_	±10	mA
I _{G2}	gate 2 current		_	±10	mA
P _{tot}	total power dissipation	T _{amb} ≤ 60 °C; see Fig.2; note 1	_	200	mW
T _{stg}	storage temperature		-65	+150	°C
Tj	operating junction temperature		_	150	°C

Note

1. Device mounted on a ceramic substrate, 8 mm \times 10 mm \times 0.7 mm.



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THERMAL CHARACTERISTICS

SYMBOL	PARAMETER	CONDITIONS	VALUE	UNIT
R _{th j-a}	thermal resistance from junction to ambient in free air	note 1	460	K/W

Note

1. Device mounted on a ceramic substrate, 8 mm \times 10 mm \times 0.7 mm.

STATIC CHARACTERISTICS

 $T_i = 25$ °C unless otherwise specified.

SYMBOL	PARAMETER	CONDITIONS	MIN.	MAX.	UNIT
±V _{(BR)G1-SS}	gate 1-source breakdown voltage	$V_{G2-S} = V_{DS} = 0; I_{G1-SS} = \pm 10 \text{ mA}$	8	20	V
±V _{(BR)G2-SS}	gate 2-source breakdown voltage	$V_{G1-S} = V_{DS} = 0$; $I_{G2-SS} = \pm 10 \text{ mA}$	8	20	V
-V _{(P)G1-S}	gate 1-source cut-off voltage	$V_{G2-S} = 4 \text{ V}; V_{DS} = 10 \text{ V}; I_D = 20 \mu\text{A}$	0.2	1.3	V
-V _{(P)G2-S}	gate 2-source cut-off voltage	$V_{G1-S} = 0$; $V_{DS} = 10 \text{ V}$; $I_D = 20 \mu\text{A}$	0.2	1.1	V
±I _{G1-SS}	gate 1 cut-off current	$V_{G2-S} = V_{DS} = 0; V_{G1-S} = \pm 7 \text{ V}$	_	25	nA
±I _{G2-SS}	gate 2 cut-off current	$V_{G1-S} = V_{DS} = 0; V_{G2-S} = \pm 7 \text{ V}$	_	25	nA

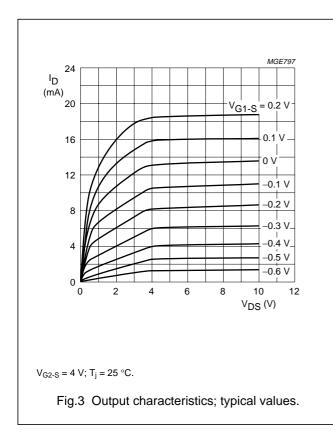
DYNAMIC CHARACTERISTICS

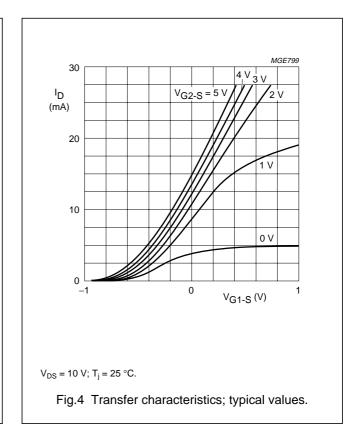
Common source; T_{amb} = 25 °C; V_{DS} = 10 V; V_{G2-S} = 4 V; I_D = 15 mA; unless otherwise specified.

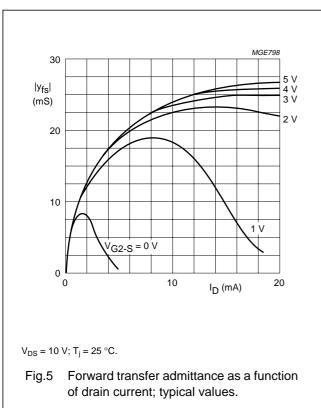
SYMBOL	PARAMETER	PARAMETER CONDITIONS		TYP.	MAX.	UNIT
y _{fs}	forward transfer admittance		20	25	_	mS
C _{ig1-s}	input capacitance at gate 1	f = 1 MHz	_	4	_	pF
C _{ig2-s}	input capacitance at gate 2	f = 1 MHz	_	1.7	_	pF
Cos	output capacitance	f = 1 MHz	_	2	_	pF
C _{rs}	reverse transfer capacitance	f = 1 MHz	_	30	40	fF
F	noise figure	f = 200 MHz; G _S = 2 mS	_	1.2	_	dB

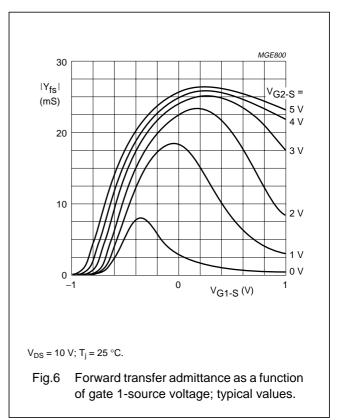
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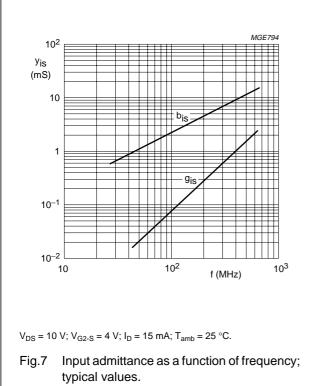


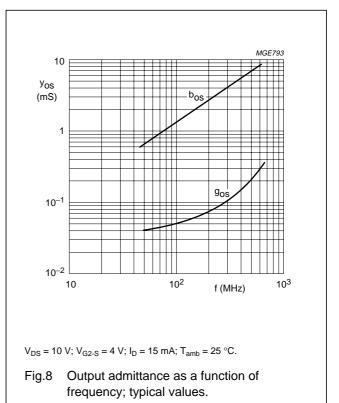
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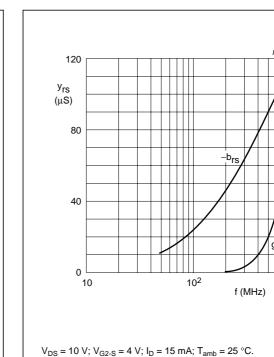




g_{fs}

-b_{fs}

10³



f (MHz) V_{DS} = 10 V; $V_{G2\text{-}S}$ = 4 V; I_D = 15 mA; T_{amb} = 25 °C. Fig.9 Forward transfer admittance as a function of frequency; typical values.

10²

Fig.10 Reverse transfer admittance as a function of frequency; typical values.

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 $|\gamma_{fs}|$

(mS)

15

10

5

0 10

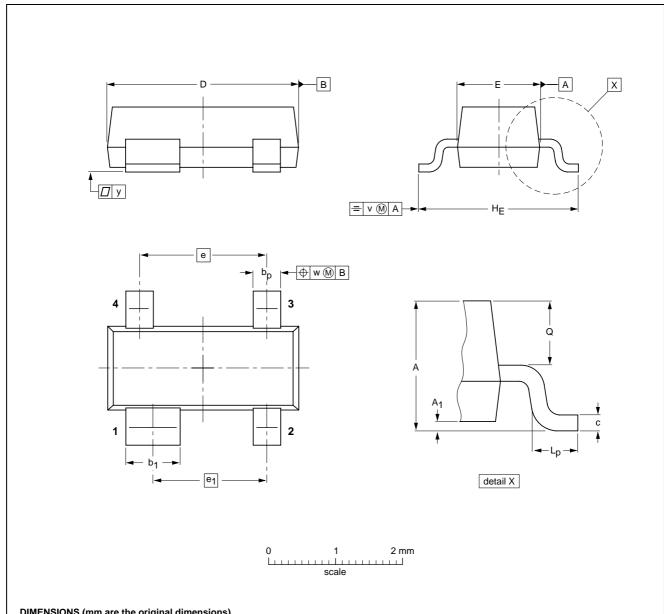
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PACKAGE OUTLINE

Plastic surface mounted package; 4 leads

SOT143B



DIMENSIONS (mm are the original dimensions)

ι	JNIT	A	A ₁ max	bp	b ₁	С	D	E	e	e ₁	HE	L _p	Q	v	w	у
	mm	1.1 0.9	0.1	0.48 0.38	0.88 0.78	0.15 0.09	3.0 2.8	1.4 1.2	1.9	1.7	2.5 2.1	0.45 0.15	0.55 0.45	0.2	0.1	0.1

OUTLINE		REFER	EUROPEAN	ISSUE DATE		
VERSION	IEC	JEDEC	EIAJ		PROJECTION	ISSUE DATE
SOT143B						97-02-28

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DEFINITIONS

Data Sheet Status					
Objective specification	This data sheet contains target or goal specifications for product development.				
Preliminary specification	This data sheet contains preliminary data; supplementary data may be published later.				
Product specification This data sheet contains final product specifications.					
Limiting values					
Limiting values given are in accordance with the Absolute Maximum Rating System (IEC 134). Stress above one or more of the limiting values may cause permanent damage to the device. These are stress ratings only and operation of the device at these or at any other conditions above those given in the Characteristics sections of the specification is not implied. Exposure to limiting values for extended periods may affect device reliability.					
Application information					

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Where application information is given, it is advisory and does not form part of the specification.

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NOTES

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NOTES

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NOTES

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